



Patent  
Attorney's Docket No. 027260-295

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of )  
)  
Kazuya KAMON ) Group Art Unit: 1756  
)  
Application No.: 09/320,946 ) Examiner: S. Mohamedulla  
)  
Filed: May 26, 1999 ) Confirmation: 5658  
)  
For: PHOTOMASK, FABRICATION )  
METHOD OF PHOTOMASK, AND )  
FABRICATION METHOD OF )  
SEMICONDUCTOR INTEGRATED )  
CIRCUIT )

6/6/02  
#19/EGT  
(amus)

**PETITION FOR EXTENSION OF TIME**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

The following extension of time is requested to respond to Office Action dated January 3, 2002:

second month to June 3, 2002; the extension fee is:

☐ \$145.00 ☒ \$290.

☒ A first month extension fee in the amount of \$ 110.00 was paid on May 3, 2002.

☐ Charge \$ \_\_\_\_\_ to Deposit Account No. 02-4800.

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

By: 

Ellen Marele Emas  
Registration No. 32,131

06/04/2002 JADD01 00000102 09320946

02 FC:116 290.00 DP

P.O. Box 1404  
Alexandria, Virginia 22313-1404  
(703) 836-6620  
Date: June 3, 2002

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